【Department Spotlight】Prof. Hung-Chung Hsueh and Chih-En Hsu Collaborate with NCKU, NTU, NSRRC to Pioneer 2D Ferroelectric Material, Reaching International Journals

Professor Hung-Chung Hsueh, Dean of Research and Development and faculty member of the Department of Physics, along with Chih-En Hsu, a third-year Ph.D. student in Applied Sciences, collaborated with research teams from National Cheng Kung University (NCKU), the National Synchrotron Radiation Research Center (NSRRC), and the Center for Condensed Matter Sciences at National Taiwan University (NTU) to publish the paper titled "Epitaxial Ferroelectric Hexagonal Boron Nitride Grown on Graphene" in the April issue of the prestigious international journal Advanced Materials, which holds an impact factor of 27.4 and a five-year impact factor of 30.2.

The team's research marks the first successful demonstration of epitaxially stacking ultrathin ferroelectric hexagonal boron nitride (h-BN) films on graphene, proving their ability to switch electric polarization stably. The findings show that the moire superlattice formed at the h-BN/graphene heterointerface induces spontaneous polarization, and interlayer sliding enables reversible switching, confirming the material's ferroelectric properties. Ferroelectricity, which refers to the ability of a material to switch electric polarization direction like an internal electric switch, is particularly well-suited for memory devices, sensors, and low-power computing technologies.

According to Hsueh, Professor Chung-Lin Wu's team at NCKU used plasma-assisted molecular beam epitaxy (MBE) to grow high-quality single-crystal graphene on a silicon carbide substrate, then precisely layered h-BN atop it. The naturally formed moiré pattern at the interface induces a polar structure with asymmetry that can be switched via an electric field. NSRRC researcher Cheng-Maw Cheng explained that the team utilized Taiwan Light Source (TLS) at NSRRC to perform angle-resolved photoemission spectroscopy (ARPES) measurements, clearly observing band structure variations in h-BN/graphene heterostructures across different h-BN layer counts. Hsueh and

Hsu used first-principles calculations, including density functional theory (DFT) for ground-state and GW many-body perturbation theory for excited-state simulations, to validate the interlayer polarization mechanism and identify the presence and characteristics of the asymmetric ferroelectric stacking structure.

This breakthrough offers a new opportunity for heteroepitaxial growth of 2D ferroelectric materials and developing tunable electronic components. It also lays the groundwork for future innovations in Taiwan's semiconductor and optoelectronic industries by designing vertically stacked heterostructure chips. Prof. Hsueh stated that through this collaboration with the research teams from NCKU, NSRRC, and NTU, the Department of Physics at Tamkang University has demonstrated its ability to integrate theoretical and experimental research while providing students with opportunities to participate in cutting-edge international research.

2025/06/03



Prof. Hung-Chung Hsueh (left) and Ph.D. student Chih-En Hsu collaborated with NCKU, NSRRC, and NTU teams. Their paper was published in the top-tier international journal Advanced Materials, which has an impact factor of 27.4 and a five-year impact factor of 30.2.

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Epitaxial Ferroelectric Hexagonal Boron Nitride Grown on Graphene

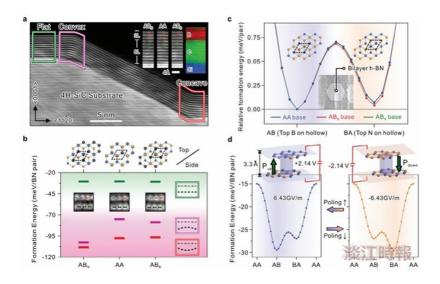
Sheng-Shong Wong, Zhen-You Lin, Sheng-Zhu Ho, Chih-En Hsu, Ping-Hung Li, Ching-Yu Chen, Yen-Fu Huang, Kuo-En Chang, Yu-Chiang Hsieh, Chia-Hao Chen, Ming-Hao Lee, Ming-Wen Chu, Kuang-I Lin, Tse-Ming Chen, Yi-Chun Chen,* Hung-Chung Hsueh,* Cheng-Maw Cheng.* and Chung-Lin Wu*

Ferroelectricity realized in van der Waals (refW) materials with non-centrosymmetric stacking configurations holds promine for future 2D devices with nonostation and reconfigurations holds promine for future 2D devices with nonostation and reconfiguration that cambes electric polarization. This challenge is particularly evident when performing heteroepistry on another wife substants to create versitie and scalable ferroelectric building blocks designed for large-area, atomic-scale thicknesses. Here, optizatio hanguana bronn sintled (n-RN) multilary films are successfully green on single-crystal graphene synthesized on a miscus SC (0001) substant. Theoretical calculations illustrate that the moin-ispattered h-RN/graphene hetero-interface intrinsically exhibit polarization, leading to a polarized AB stacking in multilayer h-RN films to minimize the total formation energy, which is validated experimentally by the layer-dependent band dispersions. The as-grown multilayer h-RN films to minimize the total formation energy, which is validated experimentally by the layer-dependent band dispersions. The as-grown multilayer h-RN films to minimize the total formation energy, which is validated experimentally by the layer-dependent band dispersions. The as-grown multilayer h-RN films to minimize the total formation energy, which is validated experimentally by the layer-dependent band superside of the complex of the comp

1. Introduction

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Prof. Hung-Chung Hsueh and Ph.D. student Chih-En Hsu from the Department of Physics, in collaboration with teams from NCKU, NSRRC, and NTU, published a paper in the top international journal Advanced Materials, which has an impact factor of 27.4 and a five-year impact factor reaching 30.2.